



AF/22

**PATENT**

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Application No.: 10/734,179  
Filing Date: December 15, 2003  
Applicant: Sang Kyun Lee et al.  
Group Art Unit: 1712  
Examiner: Margaret G. Moore  
Title: Siloxane-Based Resin Containing Germanium and Interlayer Insulating Film for Semiconductor Device Made Using the Same  
Attorney Docket: 6661-000038/US

OK for  
entry  
mgm 11/28/05

Customer Service Window  
Randolph Building  
401 Dulany Street  
Alexandria, VA 22314  
**Mail Stop Amendment**

November 17, 2005

**AMENDMENT UNDER 37 C.F.R. § 1.116**

Sir:

In response to the Final Office Action mailed August 31, 2005, please enter this Amendment and its remarks into the file of the above-identified application.

No fees are believed to be due for the filing of this Amendment. However, should any fees be required or an overpayment of fees made, please debit or credit our Deposit Account No. 08-0750, as necessary.

Amendments to the Claims begin on page 2 of this Amendment.

Remarks begin on page 4 of this Amendment.